

Abstract Submitted
for the MAR08 Meeting of
The American Physical Society

Broadband Permittivity Measurements of Ruddlesden-Popper $\text{Sr}_{n+1}\text{Ti}_n\text{O}_{3n+1}$ ($n=1,2,3$) Thin Films N. ORLOFF, W. TIAN, D. SCHLOM, J. BOOTH, I. TAKEUCHI — In order to explore the microwave dielectric response of Sr_2TiO_4 , $\text{Sr}_3\text{Ti}_2\text{O}_7$, and $\text{Sr}_4\text{Ti}_3\text{O}_{10}$ thin films, we have performed broadband in-plane quantitative complex permittivity(ϵ) measurements on $\text{Sr}_{n+1}\text{Ti}_n\text{O}_{3n+1}$ ($n=1,2,3$) thin films in the frequency range 100Hz-40GHz. The films, of approximately 160 nm thickness, were fabricated by molecular beam epitaxy[1], and standard lithographic techniques were used to define coplanar waveguide transmission lines and interdigitated capacitors using gold. We extracted ϵ from the measured complex S-parameters (.01-40GHz) and the complex impedance (100Hz-.001GHz), which were measured at 70K, 150K, 200K, and 250K using a cryogenic probe station. We found that below ~ 10 GHz the ϵ 's of these thin films were approximately constant with frequency: $\epsilon \approx 38, 48,$ and 100 for $\text{Sr}_{n+1}\text{Ti}_n\text{O}_{3n+1}$ ($n=1,2,3$) respectively. In addition, the measured value for ϵ of Sr_2TiO_4 is consistent with recent theoretical calculations [2]. We will discuss in detail the temperature and electric field dependence of the measured complex ϵ for these material systems. [1] J.H. Haeni, *et al* APL, **78**, 21 (2001) [2] C.J. Fennie and M.K. Rabe, PRB, **68**, 184111 (2003)

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Date submitted: 27 Nov 2007

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